

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80484

Tsukasa YAMANAKA, et al.

Appln. No.: 10/801,723

Confirmation No.: 1889

Group Art Unit: 1752

Filed: March 17, 2004

Examiner: Amanda C. Walke

For: POSITIVE RESIST COMPOSITION AND METHOD OF PATTERN FORMATION
USING THE SAME

RESPONSE UNDER 37 C.F.R. § 1.114(c)

MAIL STOP RCE

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the final Office Action dated April 5, 2006 and the Advisory Action dated July 24, 2006, please consider the remarks as submitted herewith on the accompanying pages. A petition for extension of time is submitted herewith, extending the due date for response to September 5, 2006.

TABLE OF CONTENTS

| | |
|---------------|---|
| REMARKS | 2 |
|---------------|---|